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Attorney Docket No.: LAM-P-1031

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): **Annapragada et al.**

Group art Unit: **2813**

Application Serial No.: **10/712,326**

Examiner: **Nguyen, Thanh T**

Filed: **November 12, 2003**

Title: **Minimizing the Loss of Barrier
Materials During Photoresist
Stripping**

AMENDMENT AND RESPONSE TO OFFICE ACTION

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir/Madam:

This Amendment and Response is submitted in response to the Office Action dated October 15, 2004 in the above referenced patent application. Please enter and consider the following amendments and remarks.

Amendments to the Claims are reflected in the listing of claims which begins on Page 2 of this paper.

Remarks begin on page 7.